Notice of Allowability	Application No.	No. Applicant(s)	
	10/658,171	GREENE ET AL.	
	Examiner	Art Unit	
	Phu K. Nguyen	2671	
The MAILING DATE of this communication appeal All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R	(OR REMAINS) CLOSED in or other appropriate communication. This application is	n this application. If not included unication will be mailed in due of	l ourse. THIS
1. \boxtimes This communication is responsive to <u>the correspondence to</u>	filed 9/8/2003.		
2. The allowed claim(s) is/are <u>18-111</u> .			
3. \boxtimes The drawings filed on <u>08 September 2003</u> are accepted by	the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority ur a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). 	been received. been received in Application	on No	on from the
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		e a reply complying with the requ	irements
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give			TICE OF
6. CORRECTED DRAWINGS (as "replacement sheets") mus (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the	on's Patent Drawing Review s Amendment / Comment on 84(c)) should be written on t	r in the Office action of he drawings in the front (not the b	ack) of
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT			te the
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview S Paper No. 8), 7. ⊠ Examiner's	formal Patent Application (PTO- ummary (PTO-413), /Mail Date Amendment/Comment Statement of Reasons for Allow	ance

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EXAMINER'S AMENDMENT:

In claim 29, line 1, replace "29" by -28--.

NOTICE OF ALLOWANCE:

The following is an examiner's statement of reasons for allowance:

A method for conservative stencil culling in a graphics pipeline.

comprising: maintaining stencil values for regions at a plurality of levels of an image pyramid; determining whether the stencil value for a region at one or more coarser levels is valid; and performing conservative stencil culling on the region utilizing the stencil value at the coarser level if the stencil value at the coarser level is valid.

A data structure comprising: <u>a valid indicator object indicating whether all</u>

<u>stencil values of a region are equal to each other;</u> and a stencil value object including <u>a stencil value equal to the stencil values of the region</u> if all of the stencil values of the region are equal to each other.

A method for multiple-pass rendering in a plurality of pipelines using conservative occlusion culling, comprising: during a first pass in a first pipeline, passing objects from an input stream to a culling stage of the first pipeline for creating an occlusion image in a first depth buffer requiring a first amount of storage; and during a second pass in a second pipeline, sending the objects to a culling stage of the second pipeline for conservatively culling occluded objects utilizing the occlusion image, and passing to a renderer remaining objects, wherein the renderer requires a second depth buffer with a second amount of storage greater than the first amount of storage.



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A system for avoiding processing in a multi-pass rendering algorithm in a graphics pipeline, comprising: means for a first pass including logic for determining whether at least a portion of the object has been culled, and logic for storing visibility information indicating whether the at least portion of the object has been culled, and means for a second pass including: logic for conditionally skipping processing in at least a portion of the graphics pipeline based on the visibility information.

A system for avoiding processing in a multi-pass rendering algorithm in a graphics pipeline, comprising: means for a first pass including logic for determining whether a last object processed within an entity of a screen is entirely visible, and logic for storing status information indicating whether the last object processed within the entity of the screen is entirely visible; and means for a second pass including logic for, when rendering each object within the entity of the screen, avoiding writing and reading z-values to and from a z-buffer if the status information indicates that the last object processed within the entity of the screen was entirely visible.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Phu K. Nguyen whose telephone number is (703)305 -9796. The examiner can normally be reached on M-F 8:00-4:30.

The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Phu K. Nguyen August 3, 2004 Shu Ngyar